

ABSTRACT

A composition for film formation according to the present disclosure is used for forming a water-repellent film on at least a part of a surface of a substrate by being supplied to the substrate, in which the surface is covered with a protic liquid, the composition containing a silylating agent which silylates the surface of the substrate, a catalytic compound which promotes a silylation reaction by the silylating agent, and an aprotic solvent, in which a content of the catalytic compound is 1.0% by mass or more with respect to 100% by mass of the composition for film formation.

Fig.1